REPLY UNDER 37 CFR §1.116 EXPEDITED PROCEDURE TECHNOLOGY CENTER 1792

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Narwankar, et al.

Application No.: 10/772,893

Filed: February 4, 2004

For: TAILORING NITROGEN PROFILE IN SILICON OXYNITRIDE USING RAPID THERMAL ANNEALING WITH AMMONIA UNDER ULTRA-LOW PRESSURE

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 Examiner: Stouffer, Kelly M.

Art Unit: 1792

Confirmation No.: 5371

2/25/09

## REPLY UNDER 37 CFR §1.116 EXPEDITED PROCEDURE

Dear Examiner:

This is in response to the Final Office Action mailed November 24, 2008.

Applicants respectfully request the Examiner to enter this Amendment and consider the following remarks.

The Listing of Claims begins on page 2 of this paper.

Remarks/Arguments begin on page 11 of this paper.

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